RADIATION PROJECT PROGRESS REPORT NUMBER 5

PARAPOTENTIAL FLOW

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It has long been recognized that the description of equilibrium electron flow in the customary terms in which the self-magnetic field of the beam is neglected is only a poor approximation in the case of intense relativistic beams. The notion of parapotential flow, or flow along equipotential lines, is put forward as the other limiting case for the purpose of understanding and designing diodes and diode regions for very energetic beams of high current. This has been gone into only in the simplest conditions, in which all accelerations are neglected and in which there is axial symmetry. The neglect of accelerations implies that the motion of an individual electron is confined to a specific R-z plane. It can then be shown that the potential is governed by the equation

$$\nabla^2 V = 2R^{-2} dI^2/dV, \qquad (1)$$

where R is the polar radius, V is the potential, and I is the current contained within the equipotential surface defined by V. The unknown function $\mathrm{dI}^2/\mathrm{dV}$ is partially determined by the necessity for introducing the parapotential condition E = βH after one integration of this equation.

Two cases have been examined, one in which the z-variation is negligible, and the other in which the R-variation is negligible. In the former case we write

$$R^{-1}\partial/\partial R(R\partial\gamma/\partial R) = R^{-2}d\mu^2/d\gamma$$
,

where γ is the total electron energy in mc² units and μ is the current in units of 17 kA. After one integration we have

$$(3\gamma/3R)^2 = 4R^{-2}(\mu^2 - \mu_0^2)$$
,

where μ_{o} is in general an arbitrary function of z. In the present notation the condition E = βH becomes

$$\partial \gamma / \partial R = 2\beta \mu / R$$

so that $\beta^2 = 1 - \gamma^{-2} = 1 - \mu_0^2 / \mu^2$, or

$$\gamma = \mu/\mu_{0}, \tag{2}$$

and $d\mu^2/d\gamma=2\mu_0^2\gamma;$ thus the original equation is linear. The complete solution is

$$\gamma = \cosh[2\mu_0 \log (R/r_0)], \qquad (3)$$

which involves two arbitrary functions of z, r_0 and μ_0 . On R = r_0 the electron energy and the electric field are zero, and therefore the interpretation of μ_0 is that it is a current which must flow within the cathode surface to produce the required conditions of the flow. If μ_0 is larger than that value which just satisfies (3) with $\gamma = \gamma_a$ (the applied anode potential) and R = r_a (the anode radius), one requires

$$\hat{\gamma} = \cosh \left(2\mu_o \log \hat{R}/r_o\right),$$

$$(\gamma_a - \hat{\gamma})/(\hat{R} \log r_a/\hat{R}) = (2\mu_o/\hat{R}) \sinh \left(2\mu_o \log \hat{R}/r_o\right)$$

in order to satisfy the potential and field continuity conditions at the beam surface, where conditions are denoted by the circumflex. If μ_0 is

less than this critical value, the flow is impossible. If $\mu_{_{\hbox{\scriptsize O}}}$ is equal to the critical current $\mu_{_{\hbox{\scriptsize C}}},$ given by

$$\mu_{c} = (\operatorname{arc cosh} \gamma_{a})/2 \log (r_{a}/r_{o}), \qquad (4)$$

the volt-ampere characteristic (conductance in mhos) is

$$i/V_a = (1/15)(1 - 1/\gamma_a)^{-1} \text{ arc cosh } \gamma_a/\log (r_a/r_o).$$
 (5)

This or higher conductances may be regarded as representing parapotential flows. The internal current is included in this value since it is generally supplied by the same source as the sheath current and results in electrons of the same energy (see Fig. 1). In nonrelativistic flows the internal, or core, current makes up most of the flow; the opposite holds for highly relativistic flows. In the particular case $\mu_{o} = \mu_{c}$ the minimum conductance occurs for $\gamma_{a} \sim 2.5$, and the corresponding conductance is

$$0.174/\log (r_a/r_o)$$
 mhos. (6)

This minimum is very broad, and little error is incurred over the range 250 keV < V $_a$ < 2 MeV if this figure is used.

In the alternative case where the R-variation can be neglected it is readily shown that the complete solution is

$$\gamma = \cosh[2\mu_o(X - \mathbf{z}/R)], \qquad (7)$$

which involves the two arbitrary functions of R, X and μ_o , which in turn depend on the cathode and beam surface shapes. If the cathode is at $z_o(R)$ and the beam surface is at z(R), then $z_o=XR$ and

$$\hat{z} - z_0 = (R/\mu_0)$$
 arc cosh \hat{y} .

In the case of a metallic cathode μ_0 is constant, so that a constant $\hat{\gamma}$ implies \hat{z} - $z_0 \propto R$. This is an obvious limiting case of the coaxial flow just discussed, in which the separation of the equipotentials is simply proportional to R. The ratio d_0/r_0 (Fig. 2) continues to play the role of an impedance, which can from previous considerations be taken to be the order of

$$5.74 \text{ d}_{0}/r_{0} \text{ ohms}.$$
 (8)

This is the <u>highest</u> impedance giving true parapotential flow for this geometry. This concept furnishes a convenient way of matching the diode to a given source impedance. The arbitrary taper is likewise useful in concentrating the flow and confining the angular spread of the beam.

The case of the parallel-plane vacuum pinch diode cannot be treated in terms of these simple models since there is no conical metallic cathode and the coincidence of flow lines and equipotentials can therefore not be satisfied throughout the flow. It is presently conjectured, however, that the flow in this tube is divided into an orthopotential (flow predominantly across equipotentials) core and a parapotential sheath, the configuration of the latter being such as to satisfy approximately the conditions derived for the conical metallic cathode down to some suitable potential, say γ_1 . Current is then injected into the parapotential portion from an outside ring (Fig. 3). The potential γ_1 is taken considerably below γ_a , so that it gives rise to a roughly conical core. This core provides the required $\mu_0(R)$ to satisfy the E = βH condition in the sheath. The regulatory mechanism for this consists in the self-adjustment of the potential γ_1 so as to provide suitable Child's-law conditions at the cathode, and we should therefore expect that the overall conductance is given in order of

magnitude by the naive expression which equates the interelectrode separation with the maximum penetration of an electron in the approximately constant electric field V_a/d and magnetic field $2i/r_o$; the resulting conductance in whos can easily be shown to be

$$0.017(1 + 1/V_{MV})^{\frac{1}{2}}(r_{o}/d), \qquad (9)$$

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where V_{MV} is V_a expressed in megavolts. Because of the orthopotential character of the core flow it is expected that core electrons will cross sheath trajectories, complicating the description of the flow. One would in fact expect that in attempts to penetrate the sheath the core electrons will encounter very large magnetic fields and thus be reflected back into the core (snowplow effect). It is expected that such effects should become less important with increasing energy, where less core current is required to satisfy the parapotential conditions at the sheath.

At least two computer programs^{1,2} have been developed for self-consistently solving such diode problems. These, however, have been plagued by instability in attempting to treat the vacuum-pinch diode. We are working on various mathematical techniques by which these instabilities can be overcome so that good perveance, cathode loading, and trajectory data can be obtained for these devices.

Three parapotential diodes have been designed and two have been built. The two that have been constructed are for the $40-\Omega$ and $7-\Omega$, 50 ns pulse generators described in references 3 and 4. These are shown in figures 4, 5, and 6. The cathodes were sent to Mr. W. Crewson of EG&G, who kindly had them tungsten-sprayed for us by AVCO.

The $40-\Omega$ diode (P-1) is actually not a good match to a $40-\Omega$ system according to (8), and the flow in this tube is in fact probably not in

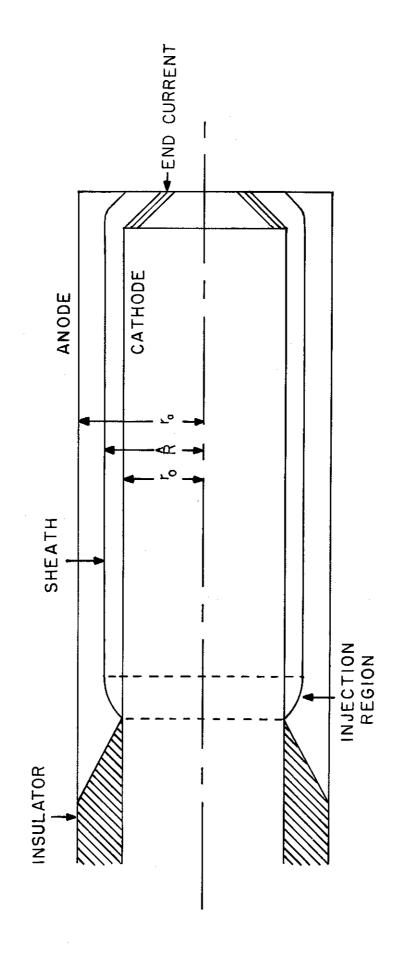
accordance with these idealistic models; it would, indeed, be hard to design a truly 40- Ω diode with the available geometry. Preliminary results on this tube, shown in Figs. 7, 8, 9, and 10, have been encouraging, however. The 7- Ω diode (P-2) is not a constant-impedance structure; it should be within a factor of 2 of matching according to (6) over about the last half of its length. The coaxial diode (P-3) shown in Fig. 11 is intended primarily for diagnostics. It is provided with a variety of probes for examining the current distribution. Its impedance according to (6) is 5.6 Ω , representing a compromise between the design impedance of 7 Ω and various mechanical considerations. It should be available for testing about 8/1/68.

FIGURE CAPTIONS

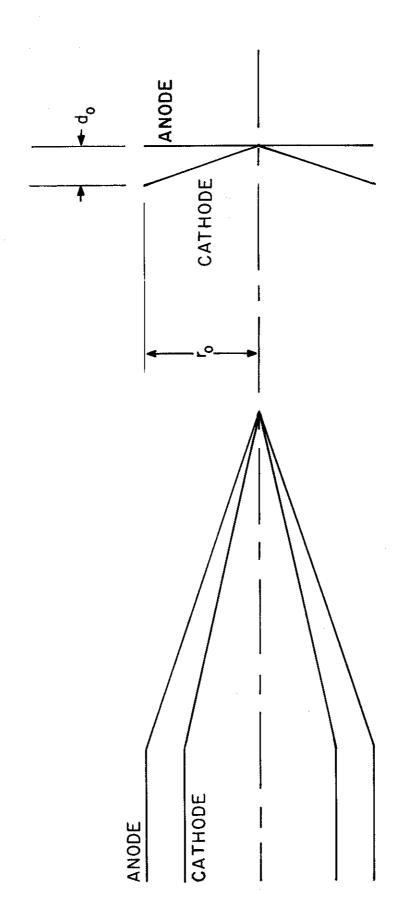
- 1. Schematic of coaxial parapotential diode.
- 2. Conical parapotential diodes of about equal impedance.
- 3. Schematic representation of vacuum-pinch flow.
- 4. Layout of conical diode (P-1) used with the 40-ohm generator.
- 5. Layout of conical diode (P-2) used with the 7-ohm water Blumlein.
- 6. Diode of figure 5 assembled to 7-ohm generator.
- 7. Anode damage in tantalum with 40-ohm generator. Estimated electron energy density ~ 100 cal/cm².
- 8. Anode damage in titanium.
- 9. Voltage and current with P-1 cathode. Voltage = 240 kV, current = 10 kA, pulse length = 50 nsec. Impedance change during pulse is substantially less than with needle array cathode.
- 10. Material buildup on cathode with aluminum anode.
- 11. Layout of coaxial diode (P-3).

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 Stanford Linear Accelerator Center Report Number 51, September, 1965.
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- 3. John J. Condon, "Radiation Project Progress Report No. 6," Measurement of Bremsstrahlung Radiation Produced with High-Current Diodes and Coaxial Blumlein Generators'," to be published.
- 4. John D. Shipman, Jr., "Radiation Project Progress" to be published.



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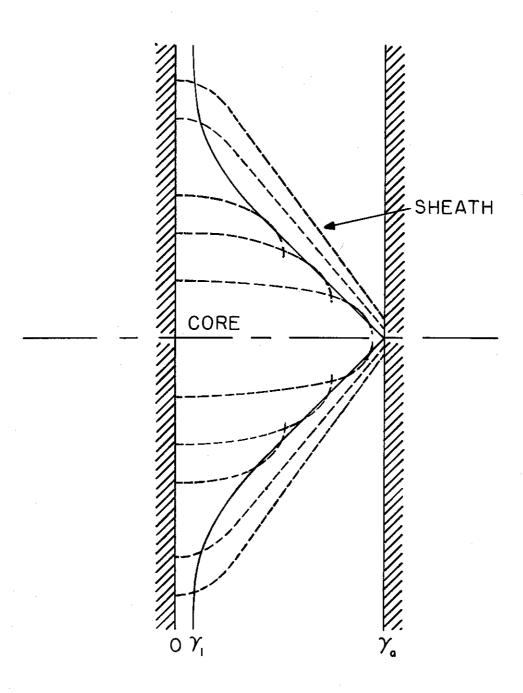
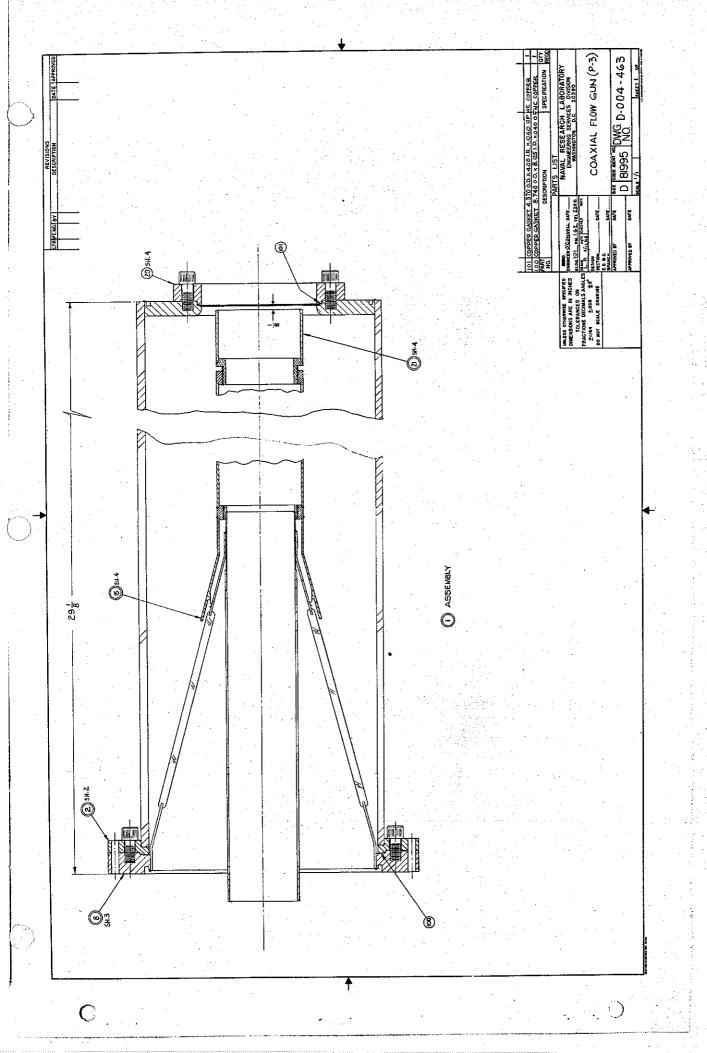
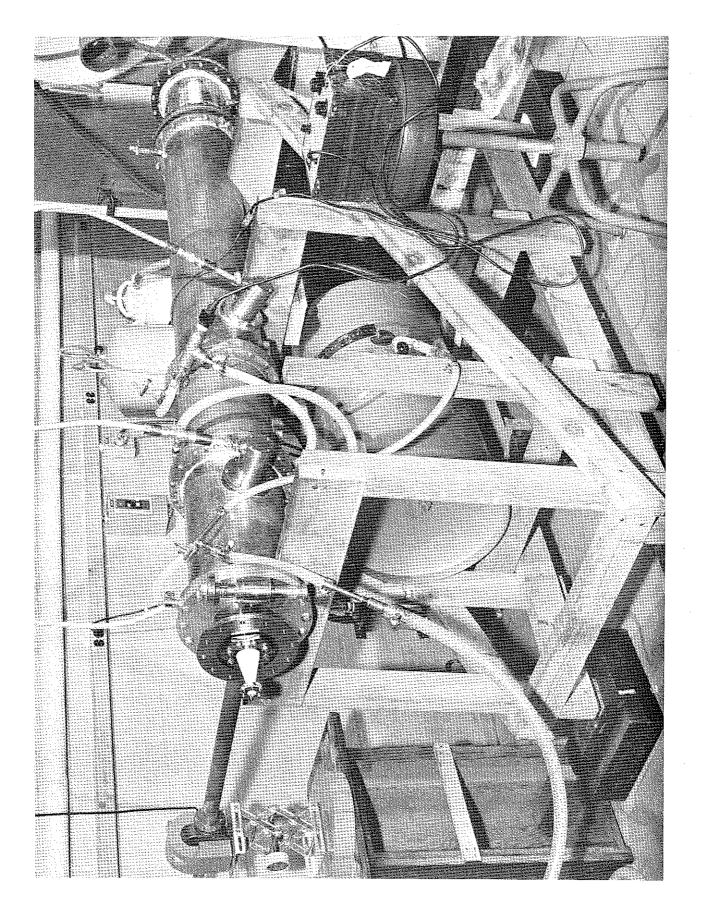


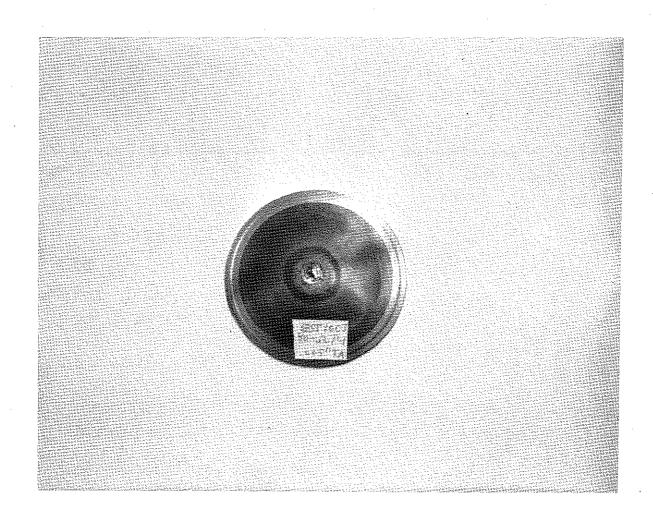
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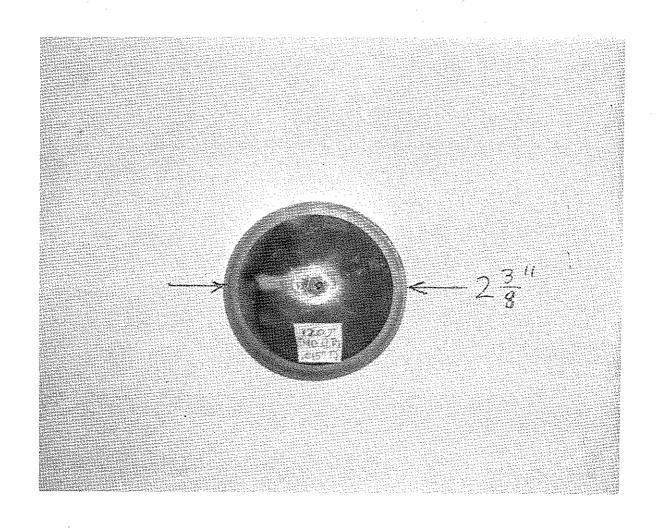
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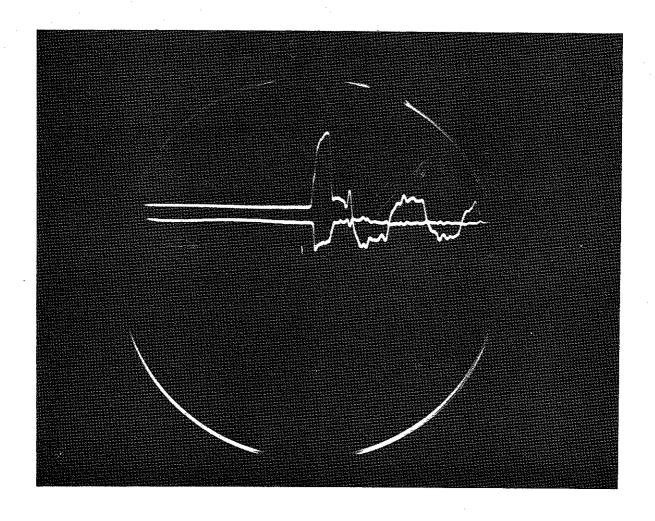
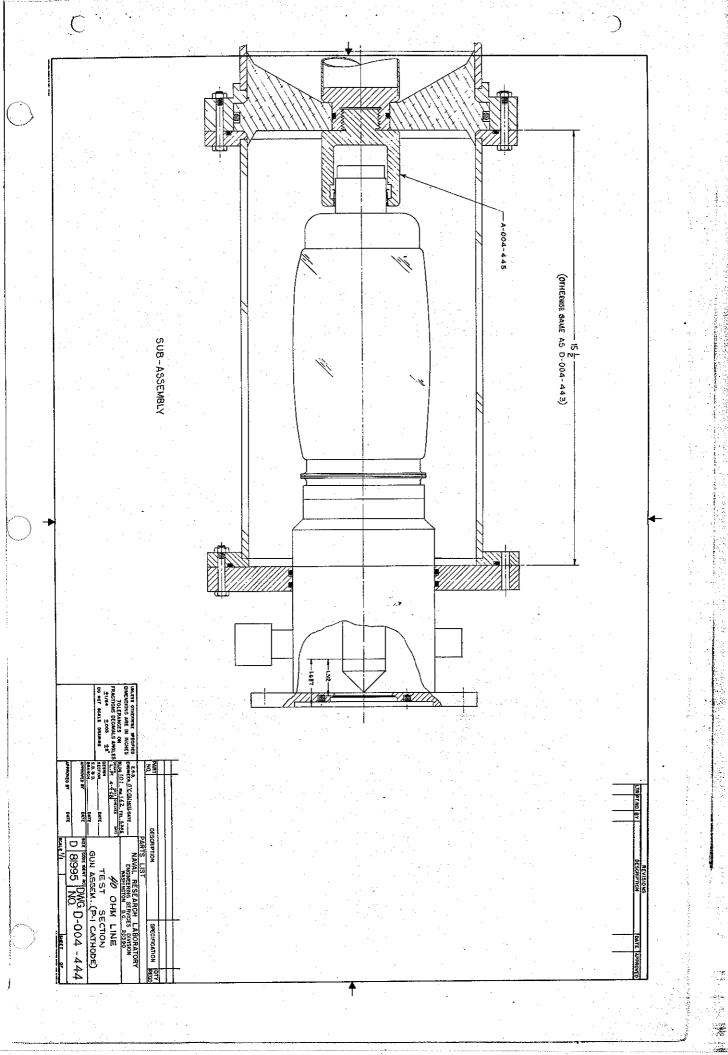
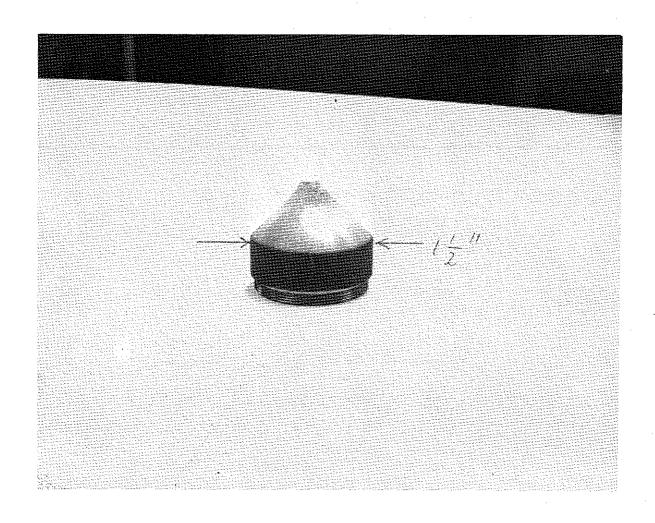


Figure - 9





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